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OPEN High potential thermoelectric figure of merit in ternary La₃Cu₃X₄ (X = P, As, Sb and Bi) compounds

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We investigate the thermoelectric properties of the relatively unexplored rare-earth ternary compounds $La_3Cu_2X_4$ (X = Bi, Sb, As, and P) using first principles electronic structure and Boltzmann transport calculations. These compounds, of which the La₂Cu₂Sb₆ and La₂Cu₂Bi₆ have previously been synthesized, are all predicted to be semiconductors and present a wide range of bandgaps varying from 0.24 eV (for the Bi compound) to 0.87 eV (for the P compound). We further find a mixture of light and heavy bands, which results in a high thermoelectric power factor. In addition, as discussed in our previous study (Phys. Rev. B 95 (22), 224306, 2017) at high temperatures of 1000 K these compounds exhibit lattice thermal conductivity less than 1W/mK. The combination of low thermal conductivity and good transport properties results in a predicted ZT as high as ~1.5 for both La₃Cu₃P₄ and La₃Cu₃As₄, under high p-type doping. This predicted high performance makes these compounds promising candidates for high temperature thermoelectric applications and thus merits further experimental investigation.

Thermoelectric materials can convert waste heat to useful electricity. The performance of a thermoelectric material is determined by the figure of merit (ZT) given by $\frac{S^2\sigma}{\sigma}$, where S is the thermopower, σ is the electrical conductivity, and κ is the thermal conductivity. The quantity $S^2\sigma$ is referred as the power factor. Over the last few decades both theoretical and experimental research on thermoelectrics has escalated due to the development of new synthesis techniques, as well as theoretical models. Favorable thermoelectric properties have been realized in several materials such as inorganic clathrates^{1,2}, skutterudites^{3–5}, magnesium group IV compounds^{6–8}, half Heusler alloys⁹⁻¹¹, SnSe¹²⁻¹⁴, and PbTe¹⁵⁻¹⁷. Additionally nanostructuring, which reduces the lattice thermal conductivity via enhanced phonon scattering can provide a route to achieve high ZT. Various theoretical and experimental studies have discussed the role of mass anisotropy^{14,16,18}, quantum confinement^{19,20}, and band structure engineering^{14,21-23} in designing materials with enhanced thermoelectric properties.

Mahan and Sofo proposed two decades ago that a delta-function electron density of states distribution near the band edge results in large thermopower²⁴. This delta function behavior in the density of states can be realized in nature by the f-electron level of the rare earth element in a material 25,26. For example, the intermetallic alloy YbAl₃, exhibits highest power factor among all known thermoelectric materials in the temperature range 100-300 K^{27,28}. This large factor is attributed to a sharp feature in the density of states near the band edge, which originates from the interaction of Yb 4f electrons with the conduction electrons. However, due to a large electronic thermal conductivity (κ_e) only a small ZT of 0.13 was achieved²⁸. On the contrary κ_e can be strongly suppressed in semiconducting rare earth compounds and more importantly they present the possibility to engender not only large power factor but also high ZT.

While some study of ternary rare earth semiconducting compounds aimed at thermoelectric applications has been carried out²⁹⁻³¹ a detailed investigation of materials properties that are essential for high $Z\bar{T}$ is still elusive. In this paper, we present a comprehensive study of the thermoelectric properties of the relatively unexplored ternary La₃Cu₃X₄ (X = P, As, Sb and Bi) compounds. As the bandgap of La₃Cu₃Sb₄ and La₃Cu₃Bi₄ is calculated to be < 0.33 eV, here we explore the possibilities of enhancing their bandgap by studying the homologous compounds such as La₃Cu₃P₄ and La₃Cu₃As₄. The latter two compounds are not known experimentally, so we asses their structural and thermodynamic stability by using structure prediction method. We found that the La₃Cu₃P₄ and La₃Cu₃As₄ also prefer the same crystal structure as the Bi and Sb counterparts. We find these compounds to be

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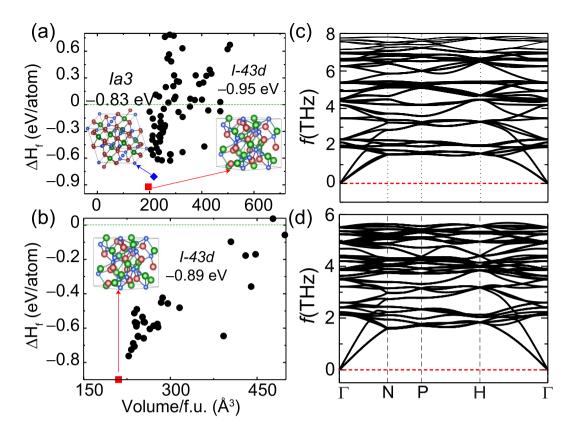


Figure 1. Formation enthalpies (ΔH_f) for various configurations of (**a**) La₃Cu₃P₄, and (**b**) La₃Cu₃As₄ calculated with respect to elemental phases as a function of volume per formula unit. The structure with space group *I*-43*d* (red square) was found to be most stable for both La₃Cu₃P₄ and La₃Cu₃As₄. The 0 eV line in (**a,b**) denotes zero formation enthalpy. The phonon dispersion curve for La₃Cu₃P₄, and La₃Cu₃As₄ are shown in part (**c,d**), respectively. The absence of negative frequencies confirms the dynamical stability of these compounds.

semiconducting with bandgaps ranging from 0.23 eV to 0.87 eV. In addition, these compounds exhibit structural and electronic features such as high band degeneracy, and combination of both heavy and light bands near the band edges, which yield high power factor. Furthermore as discussed in our recent study³², these compounds exhibit low lattice thermal conductivity ($<1\,\mathrm{W/mK}$) at high temperatures. By optimizing the ZT with respect to the doping concentrations at different temperatures, we find a peak ZT value of ~1.5 for p-type La₃Cu₃P₄ and La₃Cu₃As₄ at 1000 K at doping concentration of $7\times10^{20}\,\mathrm{cm}^{-3}$.

Results

To further investigate their stability we present phonon calculations for both structures. An enlarged version of Fig. 1(c,d) and its effect of lattice thermal conductivity is already published and discussed at length in our recent study³². Here phonon dispersions are presented to address the dynamical stability of these compounds. As shown in Fig. 1(c) the structure with the space group *I-43d* is dynamically stable, whereas the structure with space group *Ia3*, is dynamically unstable (Supplementary Information Fig. S1). For La₃Cu₃As₄ the structure with space group *I-43d* was found to be the most stable (Fig. 1(d)). This analysis suggests that the experimentally grown La₃Cu₃P₄ and La₃Cu₃As₄ would favor crystallizing in the *I-43d* space group, which is the same as the other homologous compounds La₃Cu₃Sb₄ and La₃Cu₃Sb₄ and La₃Cu₃Bi₄. The computed DFT lattice parameters of all four compounds studied here are shown in Table 1. All the calculations presented in this work are done with these optimized lattice parameters. Because of the large electronegativity difference between La and X, La transfers its electrons to

System	a_{DFT} (Å)	a _{exp} (Å)	bandgap (eV)	m _e *	m*	$\Delta E_{\rm D}$ (meV/atom)	κ _{latt} @ 300 K (W/mK)
$La_{3}Cu_{3}P_{4}^{\dagger}$	9.22	NA	0.88	0.56	1.38	190	1.3132
La ₃ Cu ₃ As ₄ [†]	9.44	NA	0.72	0.45	1.23	151	1.69 ³²
La ₃ Cu ₃ Sb ₄	9.86	9.83 ³³	0.33	0.32	0.85	93	3.35 ³²
La ₃ Cu ₃ Bi ₄	10.06	9.9733	0.24	0.38	0.76	60	2.6032

Table 1. The GGA functional optimized lattice parameters of La₃Cu₃X₄ (X = P, As, Sb, and Bi) along with the available experimental lattice parameters and other calculated results. The bandgap is calculated with TB-mBJ functional including the spin orbit coupling. To describe the thermodynamical stability, decomposition enthalpy (ΔE_D) is also given in meV/atom for all four compounds. Additionally, the room temperature lattice thermal conductivity (κ_{latt}) as calculated in ref.³² is also shown for comparison. Dagger(†), represents structures generated by particle swarm optimization (PSO) algorithm using the Calypso code.

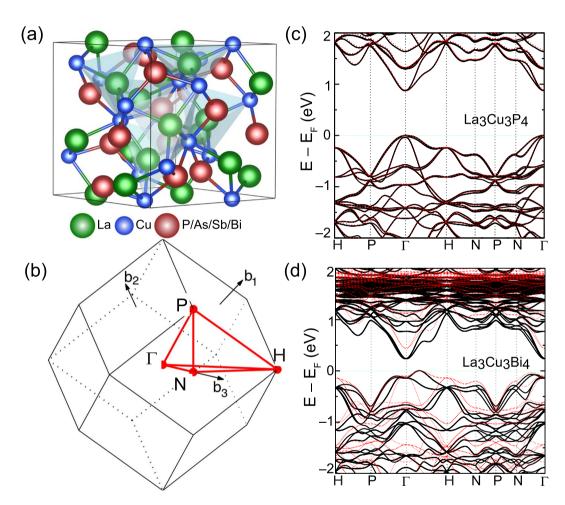


Figure 2. (a) Crystal structure, and (b) Brillouin zone for $La_3Cu_3X_4$ (X = P, As, Sb and Bi). The green, blue, and red colors represent the La, Cu, and P/As/Sb/Bi atoms, respectively. Band structure as calculated with TB-mBJ functional for (c) $La_3Cu_3P_4$, and (d) $La_3Cu_3Bi_4$. The valence band maxima is referenced to 0 eV. The solid black lines represent band structure with spin orbit coupling and dotted red lines represent band structure without spin orbit coupling.

X atoms. Hence the structure can be described as a Cu-X tetrahedron where the La atoms are separated by Cu-X tetrahedra as shown in Fig. 2(a).

Once the crystal structure of a material is known, next task is to explore its thermodynamical stability. To predict the thermodynamic stability finding a negative formation enthalpy for La₃Cu₃P₄, and La₃Cu₃As₄ with respect to their elemental phases is a very weak test of stability as most missing materials have negative formation enthalpies but are instead unstable with respect to other binary/ternary competing phases. Hence, one must verify that the compound is thermodynamically stable against decomposition, not only into the respective elements, but into *every other* possible set of constituents, including all binary and ternary phases. Thermodynamical stability of a

compound is generally described by calculating its decomposition enthalpy ($\Delta E_{\rm D}$) with respect to all other stable competing phases. Higher $\Delta E_{\rm D}$ means less probability of a phase being thermodynamically stable.

For the ternary phase diagram⁴⁴ of La-Cu-P and La-Cu-As, there are over twenty possible phases (these are listed and discussed in the Supplementary Information). We list there the formation enthalpy for all phases given by the Materials Project^{45–47} and AFLOWLIB data base^{48,49}, as well as those we have directly calculated. Fortunately, nearly all of the binary compounds listed there have formation enthalpies substantially smaller in magnitude than La₃Cu₃P₄ and La₃Cu₃As₄, so that the most potential decomposition pathways are energetically blocked. The only exception to this for La₃Cu₃P₄ are LaP and LaP₂, which show a substantial formation enthalpy magnitude of $-1.5\,\text{eV/atom}$ and $-1.1\,\text{eV/atom}$, respectively. When one assesses a potential decomposition of the prospective La₃Cu₃P₄ into LaP and LaCu₄P₃, one then finds a marginal decomposition, with the energy gained being ~190 meV/atom. Similarly for La₃Cu₃As₄; LaAs, La₄As₃ and LaAs₂ show higher formation energy than La₃Cu₃As₄. However as discussed in the Supplementary Information, on considering the decomposition of La₃Cu₃As₄ into LaAs, La₄As₃ and LaAs₂ via most favorable pathways the energy gain is only ~150 meV/ atom. While this decomposition is possible, one often finds compounds with similar marginal calculated energetics which do in fact form, potentially in a metastable configuration. For example, these same calculations find the experimentally known (with melting points above 1000 K) La₃Cu₃Sb₄ and La₃Cu₃Bi₄ compounds to also be thermodynamically unstable, with decomposition enthalpies of 93 meV/atom and 60 meV/atom, respectively as shown in Table 1. In addition, an examination of published data (The Materials Project)^{45,50} finds several known compounds in the Copper-pnictogen binary phases with high decomposition enthalpies which nonetheless form. For example, Cu₃As₄⁵¹, Cu₃N⁵², and Cu₃Sb⁵³ have calculated decomposition enthalpies of 264, 189 and 114 meV/ atom, respectively. Furthermore, in a recent study on half Heusler alloys Butler et. $a\bar{l}^{54}$ showed that the majority of half-Heusler compounds which form experimentally show decomposition enthalpies in the range of 0–100 meV/ atom. Given this we find there is a substantial probability that La₃Cu₃P₄ and La₃Cu₃As₄ will in fact form in the studied structure, and leave the matter for experimental inquiry. It is our opinion that the predicted high thermoelectric performance (described below) of this phase, if it exists, justifies experimental efforts to obtain it, despite the question about its thermodynamic stability.

Electronic structure. We begin by analyzing the band structures of $La_3Cu_3P_4$ and $La_3Cu_3Bi_4$, depicted in Fig. 2(c,d). The band structures of $La_3Cu_3As_4$ and $La_3Cu_3Sb_4$ can be found in the Supplementary Information Fig. S2. Among the four compounds $La_3Cu_3Sb_4$, and $La_3Cu_3Bi_4$ are indirect bandgap semiconductors with valence band maximum (VBM) in between Γ-H direction and conduction band minimum (CBM) at Γ point. The band structures of $La_3Cu_3Bi_4$ and $La_3Cu_3Sb_4$ are similar to the other analogs compounds such as $La_3Au_3Sb_4$ and $La_3Au_3Bi_4^{55,56}$. On the other hand $La_3Cu_3P_4$ and $La_3Cu_3As_4$ are direct gap semiconductors with both VBM and CBM at Γ point. The calculated bandgaps for $La_3Cu_3P_4$, $La_3Cu_3As_4$, $La_3Cu_3Sb_4$, and $La_3Cu_3Bi_4$ are 0.88, 0.72, 0.33, and 0.24 eV, respectively. The smaller bandgap of the Bi and Sb compounds suggest that bipolar conduction will be a concern with these materials, and therefore their thermoelectric performance will potentially be optimal at lower temperatures. The other two compounds, should be largely free from bipolar conduction even at high temperatures. The calculated density of states (DOS) for $La_3Cu_3P_4$ and $La_3Cu_3Bi_4$ are presented in Fig. 3(a,b), respectively. The DOS for $La_3Cu_3As_4$ and $La_3Cu_3Sb_4$ can be found in the Supplementary Information Fig. S3. From the DOS plots, one sees that while the valence bands for all four compounds have substantial X (X = P, As, Sb, and Bi) p character, the conduction bands have primarily Cu-s/p and Bi-p character (some contribution from La-d states can also be seen). The La-f and Cu-d states are located more than 2 eV away from the CBM and the VBM, respectively.

The most significant effect of the inclusion of spin orbit coupling is to reduce the calculated bandgap. The spin orbit coupling is rather important in $La_3Cu_3Bi_4$ and $La_3Cu_3Sb_4$, due to the relatively large atomic number of Bi/Sb. Here relevant states of Bi/Sb are p states, which experience less electronic screening and hence a stronger nuclear charge, enhancing the effect of spin-orbit coupling. The band structures calculated without spin orbit coupling are also shown in Fig. 2(c,d) by red dashed line. We find that the magnitude of spin orbit splitting increases as we go from $La_3Cu_3P_4$ to $La_3Cu_3Bi_4$. This is expected, as spin orbit Hamiltonian is stronger for larger atomic numbers. As can be seen from Fig. 2(c,d), the spin-orbit interaction not only lifts the degeneracy of the bands but also increases the splitting of bands with increasing atomic number of the X atom.

In principle, materials with complex band structures and higher band degeneracies lead to better thermoelectric performance than single parabolic bands. This can happen when multiple bands have their band extrema with little or no difference in energy (orbital degeneracy or "band convergence"), or when multiple carrier pockets in the Brillouin zone are degenerate because they are symmetrically equivalent due to the symmetry of the crystal (valley degeneracy). Generally for cubic compounds such as the ones studied here, the symmetry results in threefold degenerate p orbitals at Γ point because of the equivalency of the x, y, and z directions in the Brillouin zone. However, due to spin orbit coupling the p_z orbital splits from the p_x and p_y orbitals, where the magnitude of the splitting is determined by the strength of spin orbit coupling. As a result, the valence bands at the Γ point split into a doubly degenerate band and a nondegenerate band, mainly composed of $p_{x/y}$ and p_z orbitals, respectively which originate from atom X. As shown in the band structures due to the low atomic mass the splitting is minimal (37 meV) for La₃Cu₃P₄ and La₃Cu₃As₄. Also the dispersion of these first three bands near VBM is dramatically different; two bands being relatively heavy and one band being highly dispersive (nearly parabolic). Usually the lower splitting and a combination of heavy and light bands results in higher thermoelectric performance 14,22,23,57. This suggests that the thermoelectric performance of La₃Cu₃P₄ will be higher than that of the other compounds. On the other band the VBM for La₃Cu₃Bi₄, and La₃Cu₃Sb₄ is located slightly off the Γ along Γ -H direction resulting in no band degeneracy. Furthermore, other subsidiary maxima is located at ~80 meV below the VBM along Γ -N direction. For the most part all compounds show a considerable asymmetry between the valence and conduction bands, and therefore will behave differently under hole and electron doping. The band

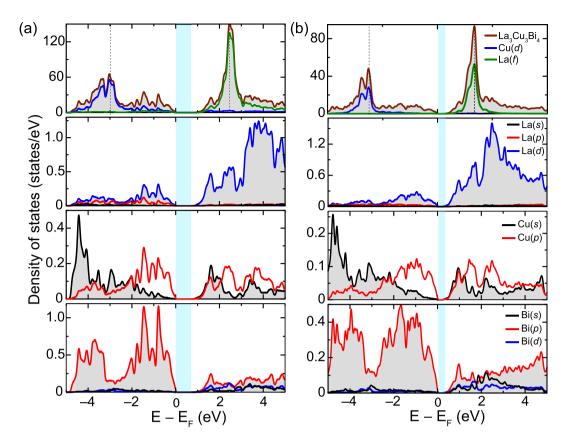


Figure 3. Total and partial density of states obtained using the TB-mBJ functional for (a) $La_3Cu_3P_4$, and (b) $La_3Cu_3Bi_4$. The valence band maxima is referenced to 0 eV. Overall DOS exhibits similar features for both compounds. Legends for (a) can be obtained by replacing Bi with P in (b).

forming the conduction band edge is more dispersive than the valence band edge. Thus, the effective mass of the holes is much larger than that of the electrons as shown in Table 1, indicating that p-doping will have higher thermopower than n-doping. The overall electronic structure of these materials is quite similar and as discussed in the next section the main factor affecting the electronic transport in these compounds is the magnitude of bandgap not the topology of the bands.

Thermopower and power factor. For a given value of carrier concentration and relaxation time, we can calculate the thermopower and electrical conductivity using Boltzmann transport theory as introduced in the Methods section. In these calculations, the thermopower and electrical conductivity tensor are calculated by integrating over all the electronic states. Figure 4(a,b) show the *p*-type thermopower for La₃Cu₃P₄, and La₃Cu₃Bi₄ as a function of carrier concentration at 300 and 1000 K. The thermopower plots for La₃Cu₃As₄, and La₃Cu₃Sb₄ are given in the Supplementary Information Fig. S4. By using the Wiedemann-Franz relation, we can rewrite the expression of ZT as, $ZT = \frac{rS^2}{L_0}$. Here $r = \kappa_e / (\kappa_e + \kappa_l)$ and L₀ is the Lorenz number for semiconductor. This relation tells us that even if the contribution of lattice thermal conductivity to ZT is ignored (r = 1), a thermopower $S = 156 \, \mu V/K$ is required to achieved a ZT of 1.

We discuss La₃Cu₃P₄ and La₃Cu₃As₄ first. The 300 K thermopower plots exhibits logarithmic dependence on carrier concentration, in agreement with Pisarenko behavior. As seen, high thermopower (>200 μ V/K) is obtained even at quite low temperatures (300 K) with doping concentration up to 5×10^{19} cm⁻³. At 1000 K for both La₃Cu₃P₄ and La₃Cu₃As₄ thermopowers in the range of $180-300~\mu$ V/K are found for hole concentrations between 6×10^{19} cm⁻³ to 2×10^{20} cm⁻³. Due to the substantial bandgap of La₃Cu₃P₄ and La₃Cu₃As₄, there are no bipolar effects and therefore thermopower keeps on increasing with temperature even at low doping concentrations. Due to the higher effective masses (presented in Table 1) the thermopower for *p*-type doping is nearly 1.5 times higher than that of *n*-type doping. Thermopower under *n*-type doping is presented in the Supplementary Information Fig. S4. Next we discuss thermopower for La₃Cu₃Sb₄ and La₃Cu₃Bi₄. With a calculated bandgap of 0.24 and 0.33 eV for Bi and Sb compound we expect significant bipolar conduction at high temperatures. The experimental measurements for hole doped thermopower of La₃Cu₃Sb₄ were carried out by Fess *et al*³⁰. Their measured 300 K thermopower of ~60 μ V/K at hole doping of 5.1×10^{20} cm⁻³ agrees well with our calculated value of $55~\mu$ V/K. As shown in Fig. 4(b) we find that 1000 K hole doped thermopower barely exceeds 200 μ V/K. The *n*-type thermopower does not even exceed $-180~\mu$ V/K (shown in Supplementry Information Fig. S4.), indicating poor thermoelectric performance under *n*-type doping.

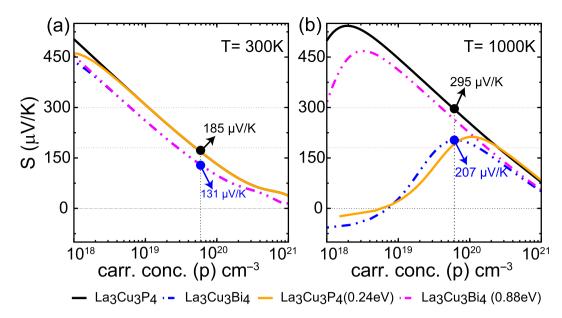


Figure 4. Calculated thermopower at (a) 300 K, and (b) 1000 K for La₃Cu₃P₄, and La₃Cu₃Bi₄. The brown dashed lines represents the limitation of thermopower (in the range of $180-300 \,\mu\text{V/K}$) for good thermoelectric materials. For comparison thermopower under *p*-type doping is also highlighted for both the compounds at carrier concentration of $6 \times 10^{19} \, \text{cm}^{-3}$. *p*-type thermopower for La₃Cu₃P₄ with the bandgap of La₃Cu₃Bi₄ (solid orange line) and *vice versa* for La₃Cu₃Bi₄ (dashed magenta lines) are also shown for comparison. Here the bandgap is modulated by applying scissor operator within the BoltzTraP code.

As explained before the main advantage of P and As compounds is their higher bandgap and density of states mass, which gives rise to large thermopower. The thermopower of La₃Cu₃P₄ and La₃Cu₃Bi₄ is compared in Fig. 4 and thermopower at hole concentration of 6×10^{19} cm⁻³ is also marked for comparison. As can be seen in Fig. 4(a), at 300 K p-type thermopower of La₃Cu₃P₄ is 1.4 times higher than that of Bi compounds. Since the bipolar effect does not come into play at room temperature the origin of this thermopower should lie in the electronic structure. As discussed before the hole effective mass is ~1.8 times higher in La₃Cu₃P₄ than in La₃Cu₃Bi₄, which contributes to its high thermopower. As we go toward higher temperatures (shown for 1000 K) bipolar effect starts to contribute for $La_3Cu_3Bi_4$ which reduces its thermopower at carrier concentration below $6\times10^{19}\,\mathrm{cm}^{-3}$. In order to quantify the gain in thermopower from the enhanced bandgap we performed thermopower calculation for La₃Cu₃P₄ with the bandgap of La₃Cu₃Bi₄ (0.24 eV) and vice versa for La₃Cu₃Bi₄. Here the bandgap was modified by applying the scissor operator within the BoltzTraP code. These results are shown in Fig. 4(a,b). As expected at room temperature for most of the carrier concentration range the thermopower obtained with the modified bandgap overlaps with the one obtained with the original bandgap. Situation is different at 1000 K. The thermopower for La₃Cu₃P₄ with 0.24 eV bandgap approaches same value as the La₃Cu₃Bi₄ themopower at carrier concentrations lower than 6×10^{19} cm⁻³ due to enhanced bipolar effects. However at higher carrier concentrations in particular past 2×10^{20} cm⁻³ the La₃Cu₃P₄ thermopower merges with the original curve. This is because, at high carrier concentrations higher effective mass of La₃Cu₃P₄ enhances its thermopower. Similarly the thermopower for La₃Cu₃Bi₄ with bandgap of 0.88 eV approaches the La₃Cu₃P₄ thermopower at low carrier concentrations. However, due to its low effective mass at high carrier concentrations, thermopower remains more or less same as the original La₃Cu₃Bi₄ thermopower. This analysis shows that the higher bandgap along with the high effective mass contributes to the higher thermopower of La₃Cu₃P₄ when compared with the smaller bandgap compound La₃Cu₃Bi₄.

In order to present more information on thermoelectric behavior, we calculate the power factor divided by the inverse scattering rate $(S^2\sigma/\tau)$, at $1000\,\mathrm{K}$, as illustrated in Fig. 5(a) for $\mathrm{La_3Cu_3P_4}$ and $\mathrm{La_3Cu_3Bi_4}$. The power factor for $\mathrm{La_3Cu_3As_4}$ and $\mathrm{La_3Cu_3Sb_4}$ can be found in the Supplementary Information Fig. S5. Also as these materials show promising thermopowers under p-type doping from this point onward mainly the results for hole doping will be discussed. Both $\mathrm{La_3Cu_3P_4}$ and $\mathrm{La_3Cu_3As_4}$ show relatively higher power factor than that of $\mathrm{La_3Cu_3Sb_4}$ and $\mathrm{La_3Cu_3Bi_4}$. To explain the high power factor for P and As compounds we plot the thermopower and σ/τ for $\mathrm{La_3Cu_3P_4}$ and $\mathrm{La_3Cu_3Bi_4}$ at $1000\,\mathrm{K}$ under p-type doping as shown in Fig. 5(b). In the typical required thermopower range for high performance thermoelectric materials $(180-200\,\mu\mathrm{V/K})$, the σ/τ of $\mathrm{La_3Cu_3P_4}$ exceeds σ/τ of $\mathrm{La_3Cu_3Bi_4}$ by more than a factor of 2.4. If the scattering time for these two compounds assumed to be the same, the electric conductivity of $\mathrm{La_3Cu_3P_4}$ should be higher than $\mathrm{La_3Cu_3Bi_4}$. The relatively high σ/τ value for $\mathrm{La_3Cu_3P_4}$ in comparison with $\mathrm{La_3Cu_3Bi_4}$ is bit surprising, as hole effective mass of former is significantly larger than the latter as shown in Table 1. For P and As compounds two weak dispersive bands degenerated at the Γ point form heavier bands, which leads to a large thermopower. Another strong dispersive band is approximately parabolic near the Γ point, which is helpful to promote its carrier mobility. Thus, the combination of these heavy and light

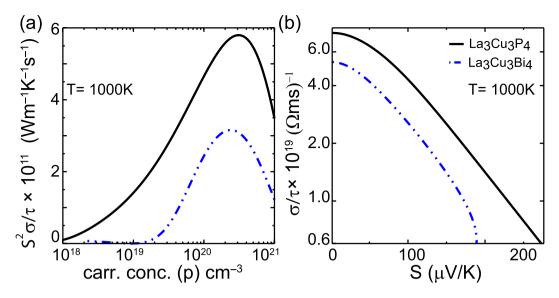


Figure 5. (a) Calculated power factor with respect to relaxation time $\left(\frac{S^2\sigma}{\tau}\right)$ at 1000 K as a function of *p*-type doping for La₃Cu₃P₄, and La₃Cu₃Bi₄. (b) $\sigma/\tau \nu s$ thermopower under *p*-type doping for La₃Cu₃P₄, and La₃Cu₃Bi₄ at 1000 K. Note that y-axis in part (b) is in log scale.

bands in the upper valence band is responsible for the relatively large thermopower and σ/τ in La₃Cu₃P₄ and La₃Cu₃As₄.

Within the framework of Boltzmann transport theory the electrical conductivity is calculated by assuming the constant relaxation time. However for a real estimate of electrical conductivity it is necessary to have information about relaxation time τ . Here, we model τ by comparing the calculated σ/τ to the experimentally measured electrical conductivity. Specifically, for p-type La₃Cu₃Sb₄, the room temperature electrical conductivity data from Fess $et~al.^{30}$ at a carrier concentration of $5.13\times10^{20}\,\mathrm{cm}^{-3}$ was used. At this doping level reported electrical conductivity is approximately $3.7\times10^4\,\mathrm{S/m}$, which yields a τ value of $3.3\times10^{-15}\,\mathrm{s}$. At last since the electronic structure near the band edge is similar for all 4 compounds, we use the same relaxation time τ for ZT calculations in all four compounds.

The lattice thermal conductivity (κ_{latt}) of these compounds was calculated in our recent work³², where a low κ_{latt} of 1W/mK was found at high temperatures (>900 K) for all four compounds. The 300 K κ_{latt} for all four compounds are reproduced in Table 1 for comparison. The κ_{latt} for La₃Cu₃Sb₄ and La₃Cu₃Bi₄ is in the range with the measured values for the other homologous compounds. For instance at 300 K a κ_{latt} of 3.8, 1.6, and 2.5 W/mK has been reported for Y₃Cu₃Sb₄⁵⁸, Ce₃Cu₃Sb₄³⁰, and La₃Cu₃Sb₄³⁰. As discussed in ref.³², the κ_{latt} for P and As compounds is comparable with the state of the art thermoelectric materials such as PbTe⁵⁹ and Bi₂Te₃^{60,61}, indicating their potential for a good thermoelectric performance. This is counter-intuitive that despite of their lower atomic masses P and As exhibit lower κ_{latt} ; as in general compounds with heavier atoms results in low value of κ_{latt} . The origin of this abnormal behavior in κ_{latt} for P and As compounds have been discussed in ref.³². Another important parameter which governs the figure of merit is the electronic contribution to the thermal conductivity (κ_e). Here κ_e is calculated by Wiedemann–Franz law.

Figure of merit. Finally we model ZT as a function of the temperature as shown in Fig. 6 for p-type doping. For ZT_{max} calculation, ZT is calculated as a function of carrier concentration at temperatures ranging from 100 K to 1000 K, and maximum value is shown in the plot. The maximum value of ZT increases with increasing doping levels and temperatures. A peak ZT of ~1.5 at 1000 K is found with a doping level of 7×10^{20} cm⁻³ for p-type doped La₃Cu₃P₄ and La₃Cu₃As₄. The ZT under n-type doping is presented in the Supplementary Information Fig. S6. Under *n*-type doping due to low power-factor (thermopower) performance is rather poorer than that of p-type and a ZT of 0.75 was achieved for La₃Cu₃P₄ and La₃Cu₃As₄. A lower ZT of 0.7 and 0.45 was achieved for La₃Cu₃Sb₄/La₃Cu₃Bi₄ under *p*-type and *n*-type doping due to their relatively lower thermopower/electrical conductivity and higher κ_{latt} . It is noteworthy that experimental values of ZT will depend on actual scattering times, so the values reported here should be taken only as first estimates. None of the less, our results indicate the potential good thermoelectric performance of p-type La₃Cu₃P₄ and La₃Cu₃As₄ at high temperatures (~1000 K). As the efficient performance is predicted at high temperatures one concern in this regard could be the melting point of these compounds. A rough estimate of melting point around 2120 K for La₃Cu₃Sb₄ was made by Fess et al.³⁰ by fitting the thermal expansion coefficient (α). However, no study is available on actual thermal stability of these compounds, hence we restrict our ZT analysis to a much lower temperature of 1000 K. Our calculations show that if the La₃Cu₃P₄ and La₃Cu₃As₄ compounds remain stable at higher temperatures such as 1500 K a much higher ZT of >2 can be achieved. Our calculated ZT values are comparable with other state of the art p-type thermoelectric materials such as skutterudites $(ZT = 0.9 \text{ at } 800 \text{ K})^{62}$, PbTe $(ZT = 1.8 \text{ at } 900 \text{ K})^{63}$, SnTe $(ZT = 1.1 \text{ at } 800 \text{ K})^{64}$, and FeNbSb (ZT = 1.5 at $1200 \,\mathrm{K}$)⁶⁵. Due to the various approximations involved in the theoretical calculations

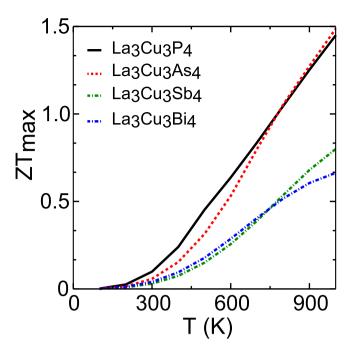


Figure 6. Calculated figure of merit as function of temperature for La₃Cu₃P₄, La₃Cu₃As₄, La₃Cu₃Sb₄, and La₃Cu₃Bi₄ under p-type doping. For ZT_{max} calculation ZT is calculated as a function of carrier concentration at temperatures 100 K to 1000 K, and maximum value is shown in the plot.

a quantitative comparison of ZT with the experimental measurements is often elusive. To put our calculated ZT values in real perspective we compare these with recent theoretical studies, where similar methodologies were employed. For instance a ZT of 1.75, 0.8, 1.75, 0.9, and 1.9 has been reported for $Mg_2Ge_{0.5}Sn_{0.5}$ (1000 K)⁷, Bi_2S_3 (750 K)⁶⁶, $BaCd_2Sb_2$ (950 K)⁶⁷, WS_2 (1500 K)⁶⁸ and Si_2Te_3 (1000 K)⁶⁹, respectively. Thus, the calculated ZT values of La based compounds are comparable with the other theoretically reported values for a variety of materials.

Discussion

We present structural, electronic and thermoelectric properties of virtually unexplored La₃Cu₃X₄ compounds. By using global structure search method with the particle swarm optimization algorithm we conclude that, the structure of La₃Cu₃P₄ and La₃Cu₃As₄ will be the same as other homologous compounds i.e. La₃Cu₃Sb₄ and La₃Cu₃Bi₄. The electronic structure calculations reveal that all four compounds studied here are semiconducting with the bandgaps in the range of 0.24 to 0.88 eV. This large bandgap for P and As compounds, while maintaining the high electrical conductivity results in nearly ~2 fold enhancement in thermopower when compared to the Sb and Bi compounds. Our results make clear that the La based ternary rare earth compounds studied here are quite likely to have high power factor, which together with low κ_{latt} as discussed in ref.³² results in high figure of merit. In particular we report that a ZT of 1.5 can be achieved for $La_3Cu_3P_4$ and $La_3Cu_3As_4$ under p-type doping at a doping level of 7×10^{20} cm⁻³. Assuming that the relaxation time (τ) does not vary significantly among these compounds, we compare the 300 K calculated figure of merit with other homologous compounds, such as Y₃Cu₃Sb₄, Ce₃Cu₃Sb₄, and La₃Cu₃Sb₄. All these compounds are narrow bandgap semiconductor with the bandgap in the range of 0.2–0.25 eV, and suffer from low figure of merit, mainly due to low thermopower (\sim 50–100 μ V/K at 300 K). For example at room temperature ZT values of 0.01, 0.03, and 0.015 have been reported for $Y_3Cu_3Sb_4^{58}$, $Ce_3Cu_3Sb_4^{30}$, and $La_3Cu_3Sb_4^{30}$, respectively. Our calculated 300 K ZT value of 0.018 for $La_3Cu_3Sb_4$ is in good agreement with experimentally measured value of 0.015^{30} . It is noteworthy that all the previous ZT measurements for these compounds are limited to room temperature where efficient performance is unlikely. Even with the low thermal conductivity, our calculation for hole doped P and As compounds find a small ZT of 0.1 and 0.06 at room temperature. The origin of enhanced figure of merit for P and As compounds at high temperatures is related to (i) their relatively larger bandgap which results in large thermopower (powerfactor) at elevated temperatures and (ii) their low thermal conductivity (as discussed in ref. 32). Our study demonstrates that if synthesized experimentally La₃Cu₃P₄ and La₃Cu₃As₄ can be potential high performance thermoelectric materials. For experimentally known and explored compounds (La₃Cu₃Sb₄ and La₃Cu₃Bi₄) our results imply that the measurements at high temperatures are required where better thermoelectric performance is anticipated. We hope that our current findings will stimulate future experimental exploration of the thermoelectric properties of these and other similar compounds.

Methods

In order to predict the structure of $La_3Cu_3P_4$ and $La_3Cu_3As_4$ we use a global structure search method with the particle swarm optimization (PSO)⁴¹ algorithm as implemented in the Calypso code⁴³. For structure prediction calculations the number of $La_3Cu_3P_4/La_3Cu_3As_4$ formula units per cell was allowed to vary from one (10 atoms) to four (40 atoms), and no restriction was placed on the space group. The number of structures in each generation

was set to 40 and the total number of generations was 15 during the structure evolution. The structures generated by Calypso at each generation are then optimized to local minima and subsequently the total energies are calculated by using the VASP code⁷⁰⁻⁷². For VASP calculations, we employ the projector augmented wave type pseudopotential and the Perdew Burke Ernzerhof (PBE) version of the exchange-correlation functional⁷⁰⁻⁷². A 500 eV kinetic energy cutoff and Γ -centered k-mesh with k-spacing of 0.4/Å were used for structure relaxation and a denser k-mesh with k-spacing of 0.15/Å for total energy calculation. During structure relaxation, both lattice constants and atom coordinates are optimized until the forces on each atom were smaller than 0.005 eV/Å.

The electronic structure calculations were performed within density functional theory using the linearized augmented plane-wave (LAPW) method with local orbitals 73,74 as implemented in the WIEN2K code 75 . The LAPW sphere radii were set to 2.5, 2.5, and 2.2 for La, Cu, and X, respectively. In addition $Rk_{max} = 9.0$, was used to ensure the well convergence of basis set, where R and k_{max} are the smallest LAPW sphere radius and interstitial plane-wave cutoff, respectively. The Brillouin zone was sampled by taking $5000\,\mathrm{k}$ -points for all crystal structures. In order to obtain an accurate bandgap, we employed a modified Becke-Johnson functional of Tran and Blaha (TB-mBJ) 76,77 . Additionally, spin orbit coupling was incorporated to account for relativistic effects. The computed electronic structures with the TB-mBJ functional were also used to obtain transport coefficients with 30000 reducible k -points. The transport calculations were done by solving Boltzmann transport equation k within the constant scattering time approximation (CSTA) k 0.

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Author Contributions

D.S.P. conceived the idea. T.P. conducted the calculations. T.P. and D.S.P. analyzed the results and wrote the manuscript.

Additional Information

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